

In the Specification-

Please amend the specification as follows:

Please enter the following replacement paragraphs:

[0033] FIGS. 1A -1D ~~is~~ are a schematic representation of the steps of the present invention involving: forming the molecular switching layer of bistable molecules on a first electrode pattern located on a substrate; forming a conductive protective layer on top of the switching layer; and applying a lithographic resist layer on top of the protective layer.

[0034] FIGS. 2A -2C ~~is~~ are a schematic representation of further steps of the present invention involving: removing resist to define a second electrode pattern; depositing electrode material onto the protective layer as defined by the resist pattern; and removing the resist.